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PATENT NUMBER and  
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10042666	FILING DATE 01/08/2002	CLASS 427 448	SUBCLASS 523	GAU 1715 1734	EXAMINER Rad. R. F. LAVILLA
<b>**APPLICANTS:</b> Han Nianci; Xu Li; Shih Hong;					
<b>**CONTINUING DATA VERIFIED:</b>					
<b>** FOREIGN APPLICATIONS VERIFIED:</b>					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO			
35 USC 119 condition's met <input type="checkbox"/> yes <input type="checkbox"/> no		003330 USA/ETCH/METAL/JB			
Verified and Acknowledged Examiners's initials					
TITLE : Process chamber having component with yttrium-aluminum coating					
U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)					

<b>NOTICE OF ALLOWANCE MAILED</b>		<b>CLAIMS ALLOWED</b>	
		Total Claims	Print Claim for O.G
Assistant Examiner		<b>DRAWING</b>	
<b>ISSUE FEE</b>		Sheets Drwg.	Figs. Drwg.
Amount Due	Date Paid	Print Fig.	
Primary Examiner		Application Examiner	
<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>		<b>PREPARED FOR ISSUE</b>	
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